

ISSUE CLASSIFICATION	
Class	Subclass

O.I.P.E.	PATENT DATE
FA SCANNED SA(4) O.A. 104	

APPLICATION NO. 09/820692	CONT/PRIOR	CLASS 438	SUBCLASS 710	ART UNIT 1765	EXAMINER chen, k
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Plasma etching of dielectric layer with selectivity to stop layer

[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)			NOTICE OF ALLOWANCE MAILED	
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<input type="checkbox"/> The terminal ____months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)			ISSUE BATCH NUMBER	

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